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Short Research Article

A novel synthesis of $({}^{2}H_{6})$ 2-methyl-3-butyn-2-ol[†]

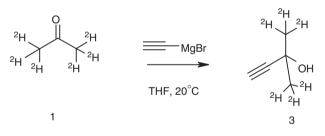
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Introduction

 $[{}^{2}H_{6}]$ 2-methyl-3-butyn-2-ol **3**, synthesized¹ from hexadeuteroacetone **1** and acetylenic Grignard reagent **2**, was required as an intermediate in the synthesis of a mass labelled internal standard. In general an increase of at least 3 a.m.u. over the test substance and a very high degree of isotopic incorporation (typically <0.1% unlabelled) is required for such a standard. MS analysis, however, of an advanced intermediate, showed ~0.5% of the corresponding unlabelled molecular ion clearly deriving from the butynol. It seemed likely that this arose from contamination of the acetylenic Grignard reaction with unlabelled acetone.

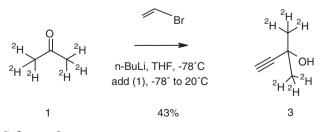




Results and discussion

A second batch of **3** was prepared as above (Scheme 1), taking extra precautions to avoid contamination by adventitious acetone. The $[^{2}H_{6}]$ acetone **1** showed (NMR) no trace of unlabelled acetone. The product **3** was derivatized by a Mannich reaction² (HCHO,

pyrrolidine. Cul) prior to LC-MS analysis, which confirmed 0.5% MO. Acetone is used in the commercial packing of acetylene³ into gas cylinders, so is likely to be a contaminant in commercial acetylenic Grignard reagents. An alternative source of an acetylenic organometallic reagent, guaranteed acetone-free, was required. Generation of acetylene by dehydrobromination⁴ of readily available vinyl bromide, under conditions that would lead to the eventual formation of monolithium acetylide, was chosen. The generation of vinyllithium from vinyl bromide and t-butyllithium is carried out at -120°C. Above -110°C, however, competitive formation of acetylene by dehydrobromination occurs.^{4a} An attempt to prepare vinyllithium from vinyl bromide and *n*-butyllithium in diethyl ether at 0° C resulted, after quenching with carbon dioxide, in a 34% yield of acetylenedicarboxylic acid, presumably via the formation^{4b} of dilithium acetylide. The stoichiometric reaction of acetylene with *n*-butyllithium at -78° C is known^{4c} to favour the formation of monolithium acetylide over that of dilithium acetylide. Treatment of vinyl bromide with one equivalent of *n*-butyllithium at -78° C generated lithium monoacetylide⁵, which was treated with hexadeuteroacetone at -78° , allowed to warm to room temperature, and the desired product 3 isolated in 43% yield. Mannich derivatization of a sample followed by LC-MS analysis confirmed that the desired product 3 had formed and contained no detectable M0 (Scheme 2).







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Conclusion

A novel method of preparing acetone-free monolithium acetylide from vinyl bromide has been developed in order to prepare $[{}^{2}H_{6}]$ 2-methyl-3-butyn-2-ol **3** suitable for use in the synthesis of a mass labelled internal standard.

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